

Presented by Leon Wu March 19, 2012

Presentation Outline



- Connector Models From Simulation
- Connector Models From Measurement
- The Post-processing, The Correlation
 - Model Quality Factor
 - Feature Selective Validation
- Channel Simulation
- Conclusions

Connector Models - Brief History



- Connector models started as simple lumped element models
- Evolved into distributed models including coupling
- Multiport microwave network simulation [S]
- Increased adoption of deembedded measurements for correlation

'70's - '80's

'80's to '90's

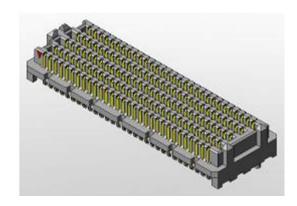
'90's to present

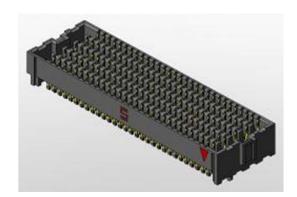
'00's to present



- For this study, we consider a high density, open pin field array connector
 - SEARAY™ SEAM/SEAF Series
- Up to 10 rows, 50 pins/row on .050" pitch (500 pins)
- Typically used in an offset GGSSGG pattern

GGSSGGSSGG SSGGSSGGSS





Typical Development Process



Mechanical Design using Solidworks

beam design, wipe, tolerances, manufacturing, plating, assembly, SI

3D Model cleanup

Knurl removal, void removal, etc.

Simulation in full wave tool (CST Microwave Studio, HFSS)

Model import, port setup, material definition, meshing

No

Interpretation of results

Is it good enough?

√Yes

End

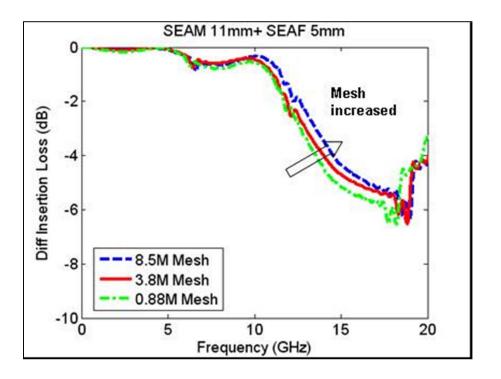
Beer drinking and celebration



- Meshing
- Material parameters
- Port setup
- Geometry capture

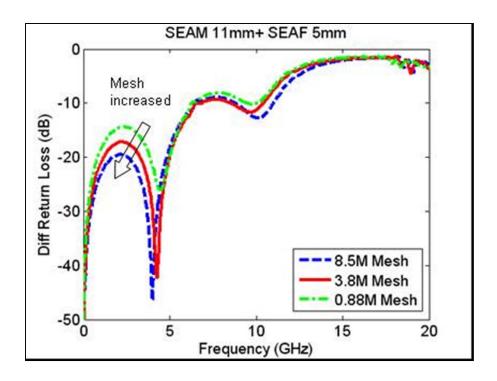


- Meshing
- Material parameters
- Port setup
- Geometry capture



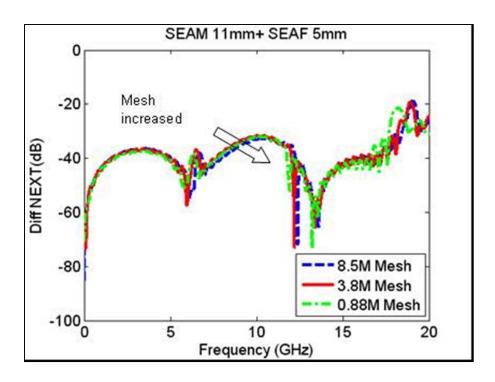


- Meshing
- Material parameters
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- Geometry capture



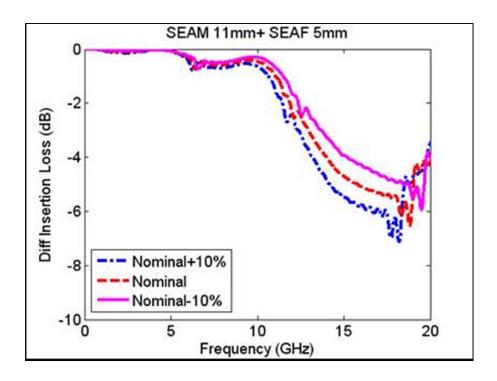


- Meshing
- Material parameters
- Port setup
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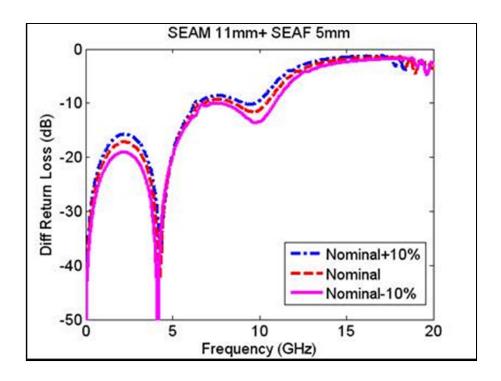


- Meshing
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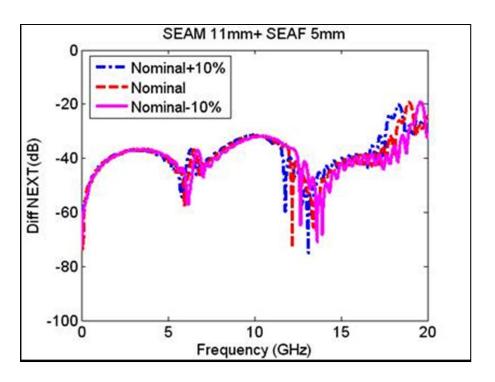


- Meshing
- Material parameters
- Port setup
- Geometry capture





- Meshing
- Material parameters
- Port setup
- Geometry capture





What could possibly go wrong?

- Meshing
- Material parameters
- Port setup
 - Coupled ports waveguide or discrete?
 - Absorbing or perfect BC?
- Geometry capture
 - Air voids?
 - Reference plane location?
 - Footprint effects?

No data here...just need "skill" with the full wave tools ©

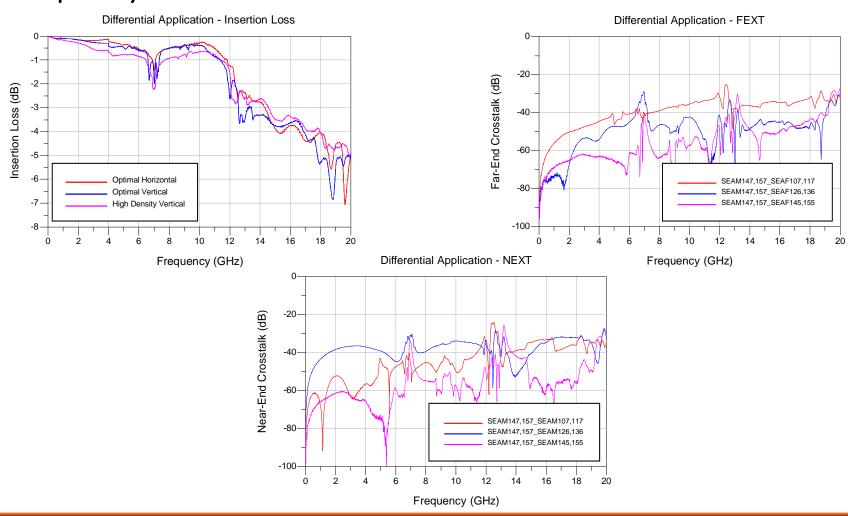
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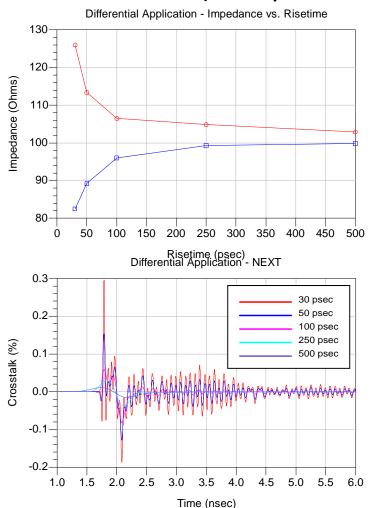


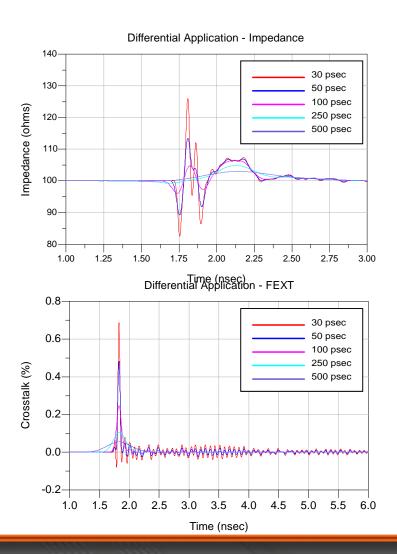
Frequency Domain





Time Domain (Post processing)





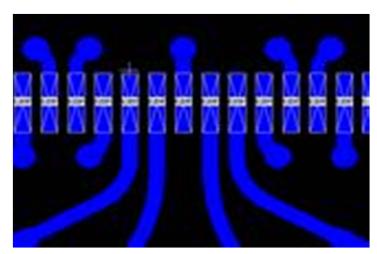


- Test board footprint (aka geometry capture)
- Insertion depth
- Soldering/attachment
- Calibration



- Test board footprint (aka geometry capture)
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Case 1 – "inboard via"

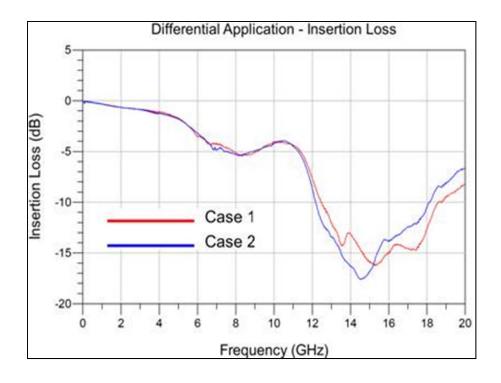


Case 2 - "outboard via"

^{*} Note – the data on the following three slides is for a 2 row FT5/FS5 Series connector. It is the only data that is not for the 16mm array SEAM/SEAF Series.



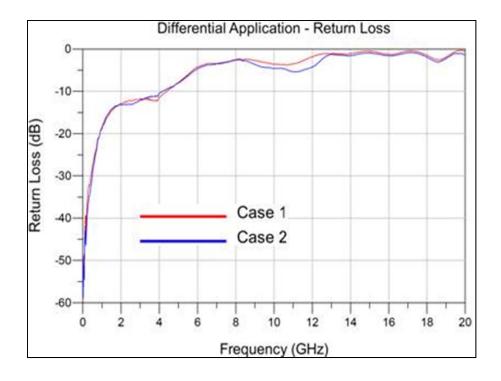
- Test board footprint
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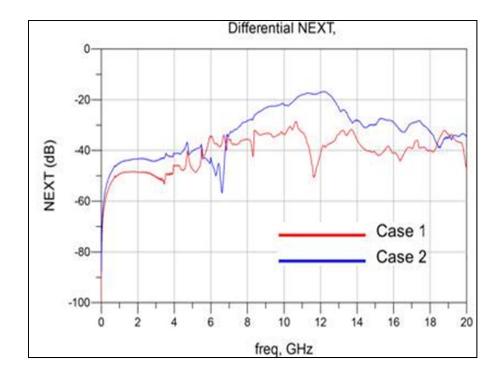
- Test board footprint
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- Test board footprint
- Insertion depth
- Soldering/attachment
- Calibration

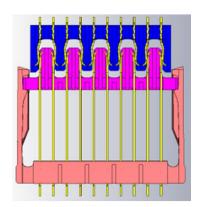


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- Test board footprint
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- Calibration

[&]quot;Fully Mated"



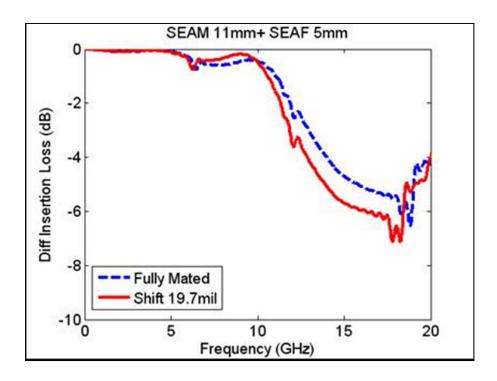
"Shift 19.7 mils"

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What could possibly go wrong?

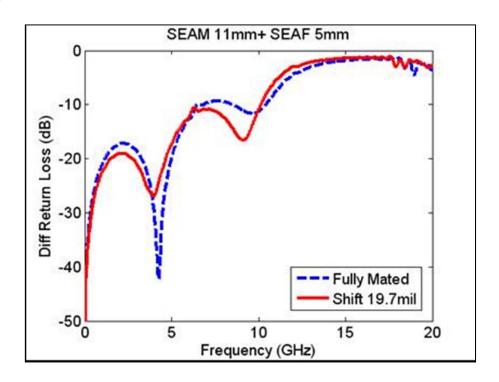
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* Note – the data on this slide is derived from simulation.



- Test board footprint
- Insertion depth
- Soldering/attachment
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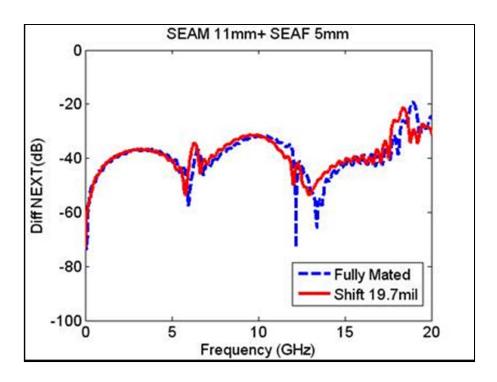


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What could possibly go wrong?

- Test board footprint
- Insertion depth
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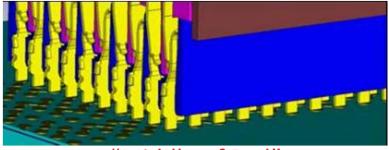


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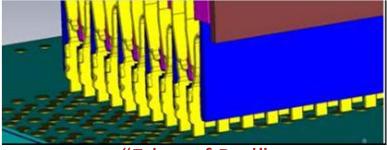


What could possibly go wrong?

- Test board footprint
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- Calibration



"Middle of Pad"

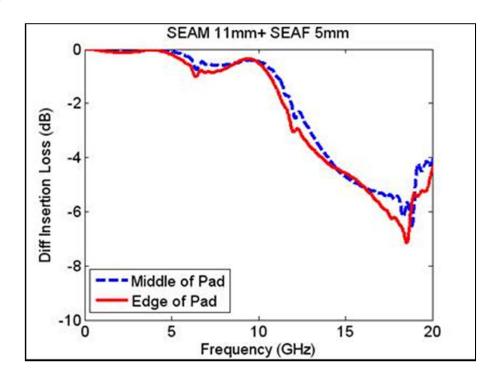


"Edge of Pad"

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- Test board footprint
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- Calibration

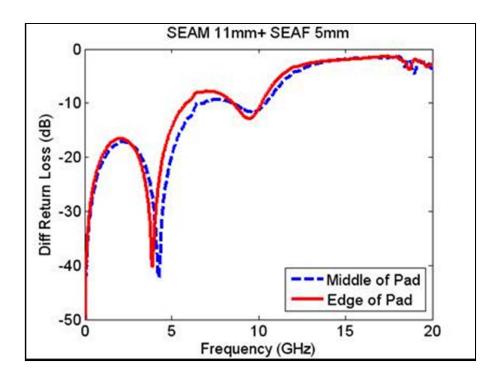


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What could possibly go wrong?

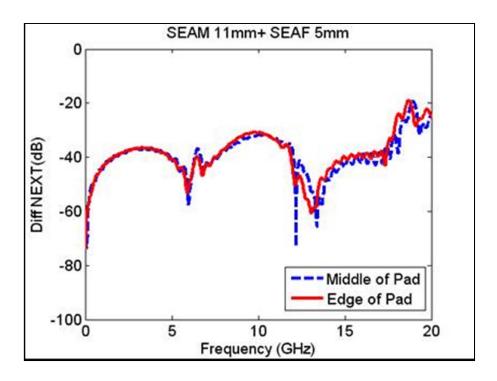
- Test board footprint
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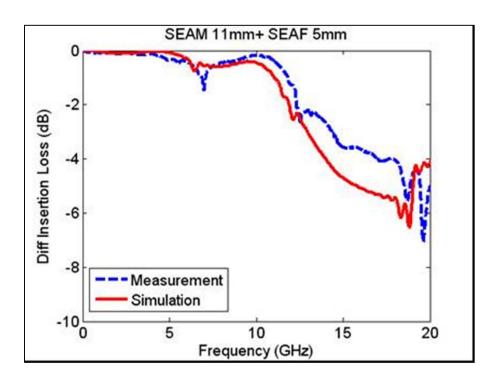


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How well do the measurements match the simulation?

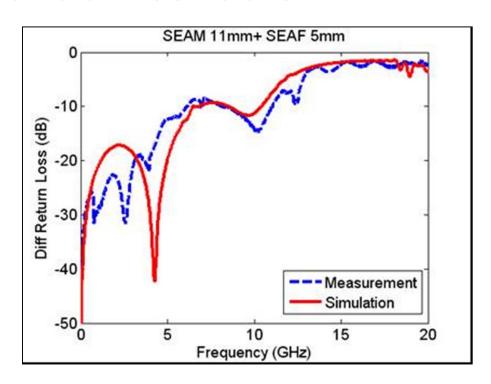
– Good?





How well do the measurements match the simulation?

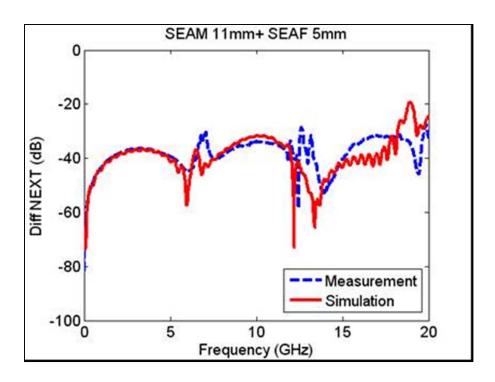
– So-so?





How well do the measurements match the simulation?

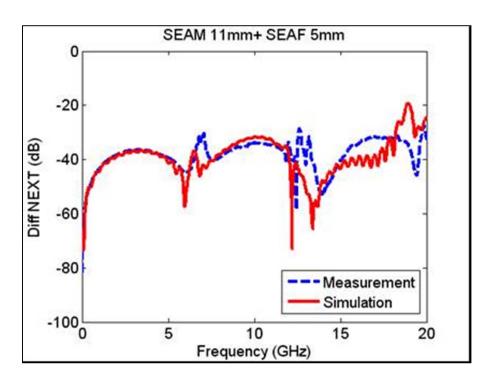
– Not too shabby?





How well do the measurements match the simulation?

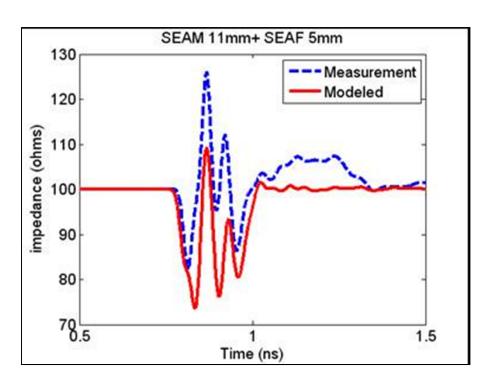
– Not too shabby?





How well do the measurements match the simulation?

– Solid "B" work?



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Model correlation can be quantified to avoid qualitative judgment ("not too shabby of a match")

Method 1 – Model Quality Factor (MQF) championed by Intel

- Requires the computation of areas under a curve
- Big xx good correlation
- Small xx poor correlation

$$MQF = log_{10} \frac{x_1}{x_2}$$

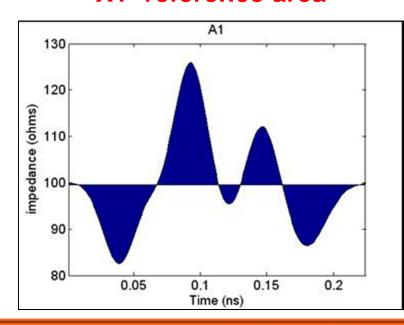
- xx= Model Quality Factor for impedance, insertion loss and crosstalk
- x₁= reference area
- x₂= area between measured and simulated curves



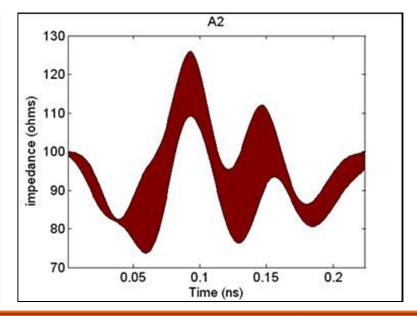
Impedance MQF = -0.15

$$MQF = log_{10} \frac{x_1}{x_2}$$

X1- reference area



X2- area between curves



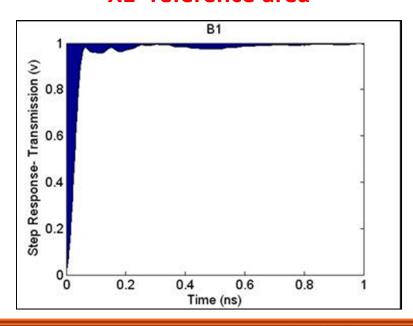


Insertion Loss MQF = 0.43

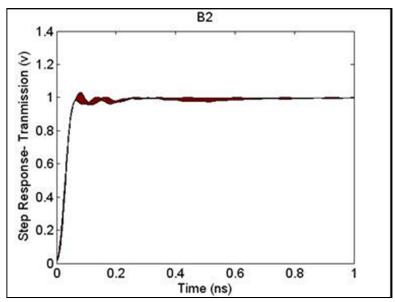
Insertion Loss is computed as the Time Domain transmission

$$MQF = log_{10} \frac{x_1}{x_2}$$

X1- reference area



X2- area between curves



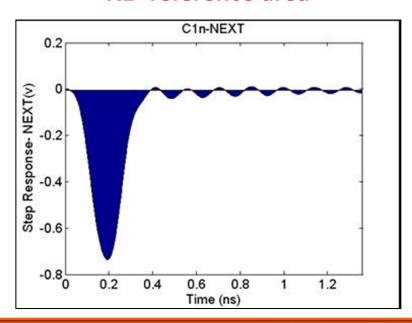


Near End Crosstalk (NEXT) MQF = 0.85

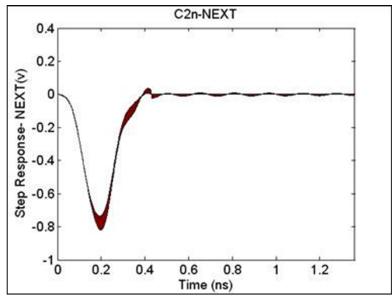
NEXT is computed in the Time Domain

$$MQF = log_{10} \frac{x_1}{x_2}$$

X1- reference area



X2- area between curves



MQF Observations



- MQF does change with Rise Time
 - The Time Domain waveforms were computed using [S] and Agilent ADS 2011.05, and the output depends on the input
- MQF is computed over the region of interest
 - Time window span impacts MQF and is defined in the document

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Feature Selective Validation



Feature Selective Validation (FSV) is a method with three components:

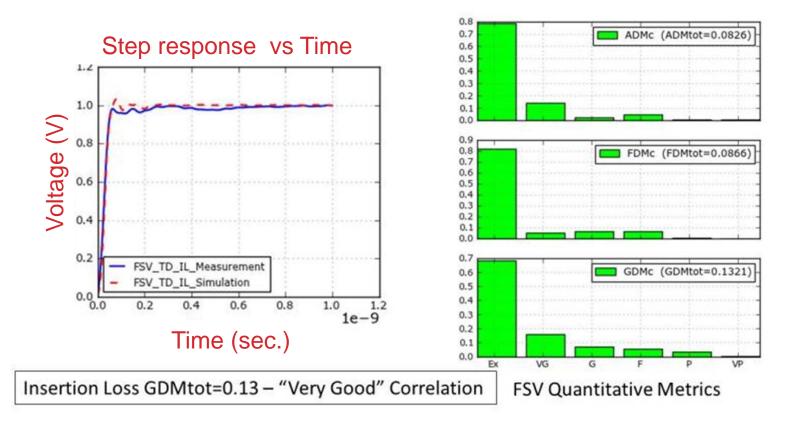
- Amplitude Difference Measure (ADM)
 - Absolute difference between two data sets
- Feature Difference Measure (FDM)
 - Calculate the first derivative of the data sets to accentuate the change or "features" in the data
- Global Difference Measure (GDM) is the geometric mean of ADM and FDM. GDM is the overall quality metric.

Small values of ADM, FDM and GDM means good correlation while high values mean poor correlation (opposite of MQF)

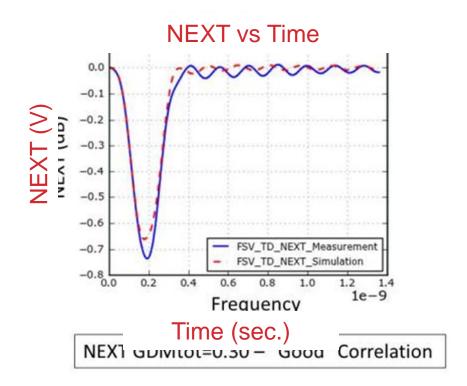
Numeric values of XDM are mapped to qualitative terms (Excellent, Very Good, Good, Fair, Poor, Very Poor)

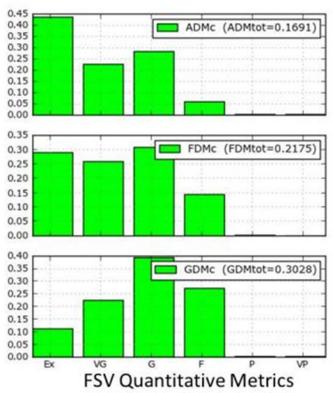
FSV – Insertion Loss





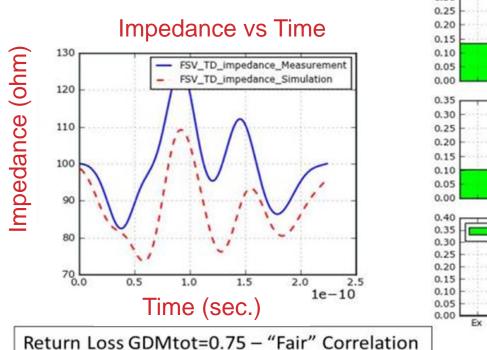


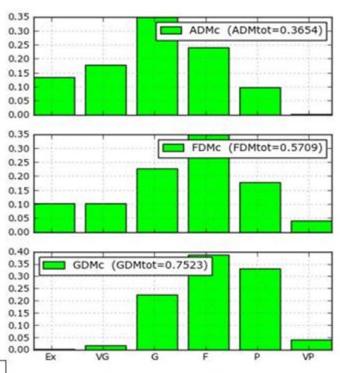




FSV – Impedance







FSV Quantitative Metrics

Additional Work on Impedance and Calibration



- The reference impedance of a TRL/M measurement is the line standard impedance
- This means the "measured" connector impedance can shift depending on the calibration standards
- Consider an experiment where we adjust the simulated impedance based on the measured calibration standards

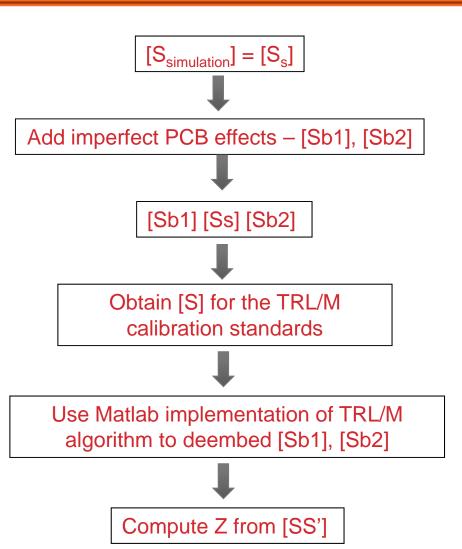
"Real World" Board Effects



The approach – add "Real World" board effects to simulated response:

Simulate the connector as usual and obtain [S]

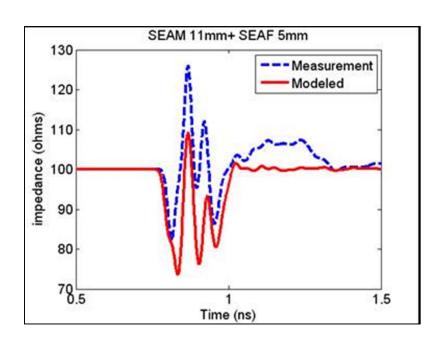
- Using ADS, add 46 ohm transmission line elements to [S]; these represent the actual measured trace values from the test boards
- Measure the line standards using an
 SOLT calibration note that these are not
 ohms
- Perform an external TRL/M calibration using Matlab to remove the 46 ohm transmission line elements on [S]
- Use this re-compiled simulation data
 and compare to the measured data

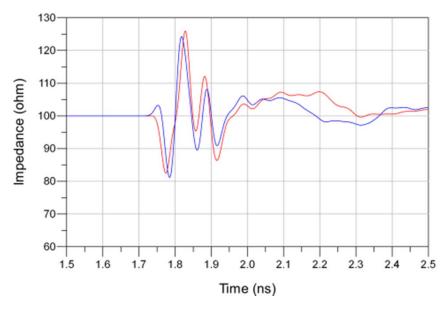


"Real World" Board Effects



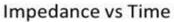
Applying "Real World" imperfections of test boards result in much better impedance match

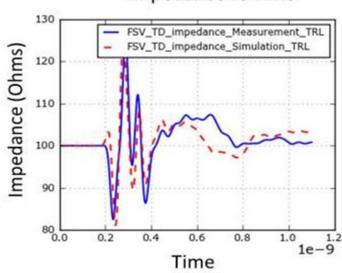




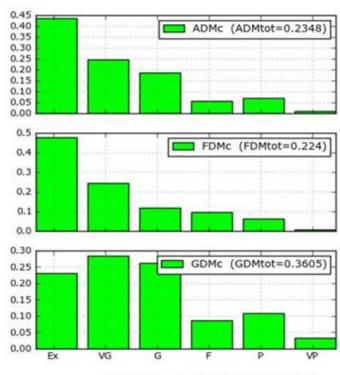
FSV – Impedance







NEXT GDMtot=0.36 - "Good" Correlation



FSV Quantitative Metrics

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Channel Simulation Setup

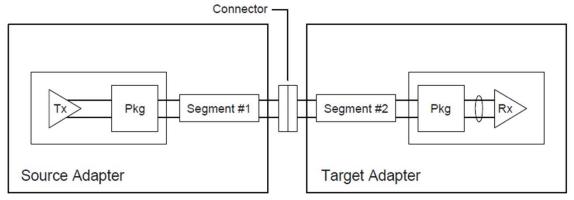


In the channel simulation, ADS includes the Tx and Rx package models which are released by PCI-SIG.org, as defined by the PCI Express Base Specification, Rev 3.0 for 8.0 GT/s channel compliance testing

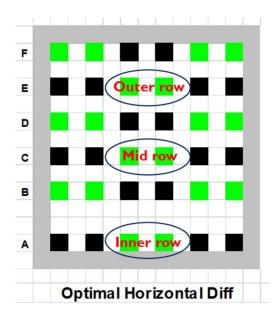
A variable length interconnect trace segment on the source adapter, with and without a 200 nF capacitor

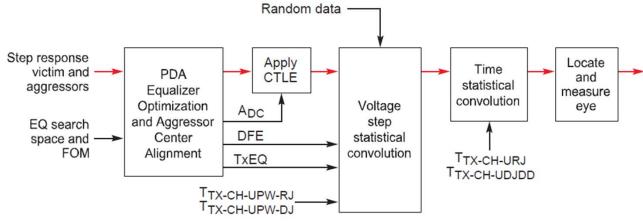
A variable length interconnect trace segment on the target adapter

A Samtec SEAM-RA/SEAF-RA SEARAY™ Series connector touchstone S-parameter model



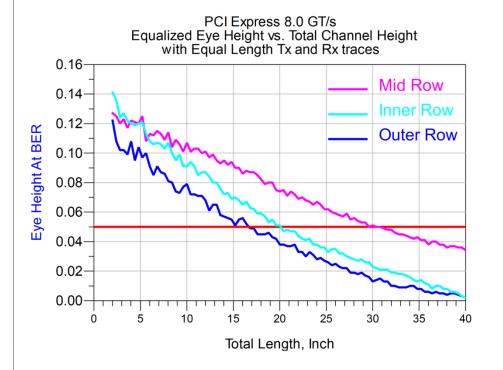


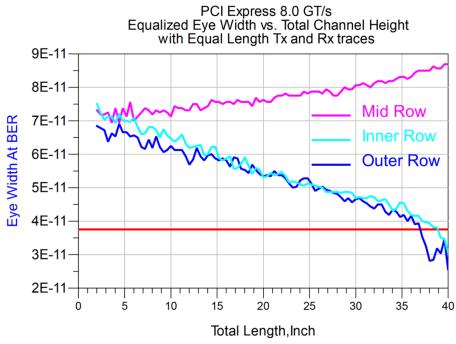




The Performance

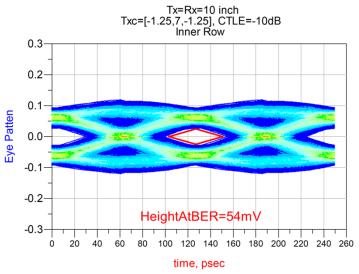


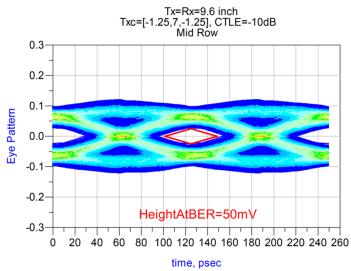


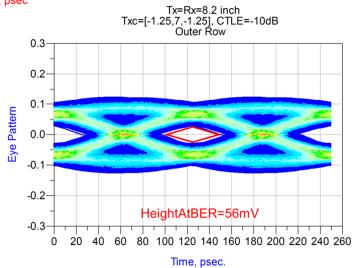


The Performance









References



- MQF

- Intel Corporation, "Intel Connector Model, Quality Assessment Methodology", September 2011
- http://www.intel.com/content/www/us/en/architecture-andtechnology/intel-connector-model-paper.html

– FSV

- Universitat Politecnica De Catalunya, FSV downloadable code
- www.upd.edu/web/gcem
- A.P. Duffy, A.J.M. Martin, A Orlandi, G Antonini, T.M. Benson, M.S. Woolfson, "Feature Selective Validation (FSV) for validation of computational electromagnetics (CEM). Part I The FSV method", IEEE Trans. on Electromagn. Compatibility, Vol 48, No 3, Aug 2006, pp 449 459.

Conclusion



- Measured and modeled connector models can have a high degree of correlation provided test fixture artifacts are properly accounted for
- We introduced two different metrics for model correlation:
 - MQF Model Quality Factor
 - FSV Feature Selective Validation
- Samtec has developed a PCIe Gen 3 analysis suite with ADS
 - Includes FIR, CTLE and DFE equalization as per PCIe Gen 3
 - Batch simulation and parameter sweeps are used to select the optimum equalization settings
 - Tx and Rx effects (jitter, package parasitics) are included in the suite

